19. Cooling Techniques for High Density Electronics (1)

Cold Plate Technology for High Density Server

19-1 Introduction

Most cold plates based on water cooling for computers was introduced more than twenty years ago, but had disappeared from the mainstream by the mid 1990s. The conversion of chip technology from bipolar to CMOS (complementary metal oxide semiconductor) was the main reason. As chip powers continue to increase, water cooling appears likely to become main stream again. In the current market, the major benefits of changing from air to water cooling are increased packaging density and lower power noise. Among the systems most likely to benefit are rackmount servers, both 1 unit (1U = 44.45 mm) and blade configurations with even more severe space requirements.

In the near future, water cooling of processors and air cooling of other components may be introduced. The water (or refrigerant) used to cool the processors would transfer heat to the outside environment, probably through the building water supply, avoiding the CRAC (computer room air conditioner) units. The capital cost, energy consumption and floor space required by the CRAC units would be significantly reduced. In a case study by Prechtl and Kurtz, a total (server plus cooling) power reduction of 23% and CRAC power reduction of 50% were found.

A	Wetted surface area	m ²
С	Thermal conductance	W/K
C _p	Thermal capacity	J/kgK
3	Effectiveness	-
h	Heat transfer coefficient	W/m ² K
• m	Mass flow rate	kg/s
NTU	Number of transfer units	-

19-2 Parameters affected on Cold Plate Performances Nomenclature

The volume of water required per hour will be slightly lower than the volume of air required per second to provide the same thermal capacity. The convective resistance of a cold plate or heat sink and the thermal capacity of the coolant are related by:

$$NTU = hA/(mC_p)$$
(19.1)
The effectiveness of a cold plate or heat sink is the ratio of heat transferred to the ideal case in which all fluid achieves the surface temperature:

$$\varepsilon = 1 - \exp(-\text{NTU}) \tag{19.2}$$

The resulting thermal conductance is given by:

 $C = \varepsilon m^{\bullet} Cp$

(19.3)

For a fixed pressure drop, thermal conductance is maximized at NTU = 1, resulting in $\varepsilon = 0.63$. For a fixed pumping power (the product of volume flow rate and pressure drop), thermal conductance is maximized at NTU = 1.9, resulting in $\varepsilon = 0.85$. Cold plates with effectiveness lower than optimum require excessive flow; those with effectiveness higher than optimum require excessive pressure drop.







Part C: Electronics Cooling Methods in Industry

Achieving such high values of effectiveness in a small form factor has historically been a manufacturing challenge. Even large cold plates for multichip modules, over 100 mm square, required only a few flow channels making several passes back and forth across the cold plate. CNC (computer numerically controlled) machining has practical limits of about 0.5 mm channel width and 0.5 mm fin thickness. Inserted folded fins also have limits of about 0.5 mm in channel width, but can use finstock to about 0.2 mm thickness. Even 0.5 mm channels result in small values of effectiveness for typical single-chip size cold plates, and smaller dimensions are required to achieve optimum effectiveness.

For the purposes of this article, a conventional cold plate is defined as one in which coolant channels are parallel and run from one side of the cold plate to the other. This can also include cases in which coolant channels turn back and forth across the face of the heat source(s). An experiment simulated 60 x 64 mm cold plates with channels 1 to 3 mm wide. Figure 19.1 shows velocity and temperature distributions at 1 m/s. With 20 channels 3 mm wide, variations in velocity and temperature are much greater than with 60 channels 1 mm wide.







19-3 Manifold Flow Distribution

Improvement of the conductance of cold plates has been studied but new designs have seldom been implemented. Harpole and Eninger proposed a manifold microchannel in which alternate inlet and outlet channels guided flow in and out of parallel channels. In their case, the optimum dimensions were quite small. Manifold channel spacing was 333 μ m, fin height 167 μ m and channel width 7 to 14 μ m, with the ratio of fin thickness to channel width from 0.5 to 1.0, significantly smaller than dimensions considered practical for fabrication in copper.

Manifolding has appeared in recent commercial products. Valenzuela and Jasinski describe a normal flow cold plate (NCP) with alternating inlet and outlet manifold channels approximately 1 mm wide. Figure 19.2 shows a cutaway view of the NCP. The heat transfer matrix is quite thin but not described in detail. Effectiveness values of 0.8 at low flow rates and 0.6 at high flow rates were demonstrated. North and Cho tested an assembly with a multistage manifold, as shown in Figure 19.3. Coolant enters the inlet port (1), is distributed to a manifold inlet channel (2), then flows the short path through the heat transfer matrix (3) into the adjacent outlet channel (4) and finally through the outlet port (5).







Figure 19.3a Powdered metal cold plate (PCMP) assembly









Figure 19.3b Coolant flow path

Patterson et al. Considered four possible arrangements for multilevel flow: single level flow (1F), parallel flow (PF), counter flow (CF) and series flow (SF), shown in Figure 19.4. Their goals were reduction of both average wall temperature and wall temperature variation. Results with silicon and water at an inlet velocity of 1 m/s are shown in Figure 19.5. While series flow achieves good uniformity, the wall temperature rise is high. The counter flow arrangement provides low and uniform values of wall temperature rise.



Figure 19.4 Flow arrangements







Part C: Electronics Cooling Methods in Industry

Figure 19.5 Wall temperature distributions

19-4 Nontraditional Heat Transfer Surfaces

Heat transfer surfaces other than parallel plate fins have also emerged. North and Cho described a porous metal heat sink in which spheroid particles are bonded together, shown in Figure 19.6. Nominal particle diameters were 274, 325 and 537 μ m. Prechtl and Kurtz presented a microstructured fabrication process in which etched layers were joined together to form a multilayer heat sink, as shown in Figure 19.7. The resulting channels were 400 x 600, 200 x 300 and 100 x 200 μ m.



Figure 19.7 Microstructure cold plate fabrication process





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Muller and Frechette presented a comprehensive numerical study of manifold microchannel heat sinks. With copper and water, using 1 cm^2 as the reference area, a thermal conductance of 15.5 W/K could be achieved with 0.005 W pumping power, significantly higher performance than achieved to date. A zigzag fin configuration was introduced, which could lead to even further improvement in performance.

19-5 Conclusions

A complete evaluation of cold plate performance requires measurement of flow rate, thermal resistance and pressure drop. Flow rate and thermal resistance for cold plates of different size must be normalized to a unit surface area, traditionally 1 cm². Figure 19.8 shows normalized thermal resistance and pressure drop as functions of volume flow rate per unit area for a normal flow cold plate. At the lowest flow rate, effectiveness is about 63%, corresponding to NTU = 1, the optimum value for fixed pressure drop. Small differences in pressure drop at different values of heat flux reflect changes in fluid properties with temperature.



Figure 19.8b Ultra high flux NCP hydraulic performance





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In air cooling, nonoptimized heat sinks were adequate until quite recently. The current need for minimization of noise, fan power, heat sink volume and weight have forced optimized designs into production. As a result of volume production, manufacturing techniques such as soldered stacked fins have seen significant reductions in cost. Manufacturing techniques, which allow variation of both the manifold and coolant channel dimensions, will permit the effectiveness of the cold plate to be optimized. Once water cooling becomes mainstream, the dual expectations of designs moving closer to optimized values and reduction of manufacturing cost through volume are reasonable.





